



Европейски съюз

"Подкрепа за развитието на човешките ресурси в областта на научните изследвания и иновации в Русенския университет"



Европейски социален фонд



финансиран по Оперативна програма „Наука и образование за интелигентен растеж 2014-2020“



Department „*Materials science and technology*“
Center for technology transfer in Ruse University "A. Kanchev"

Advanced Engineered Solutions

A Global Leader in



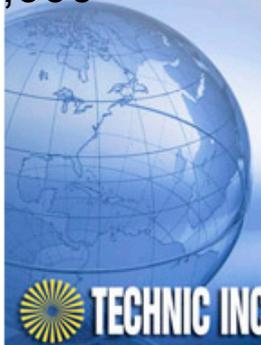
- Specialty Chemicals
- Surface Finishing Equipment
- Engineered Powders
- Analytical Controls



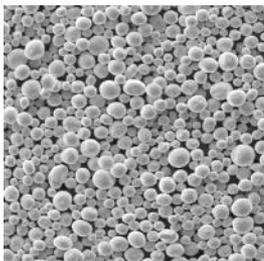
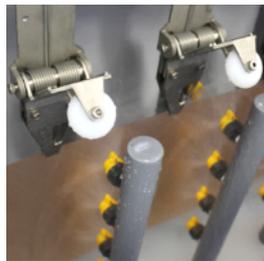
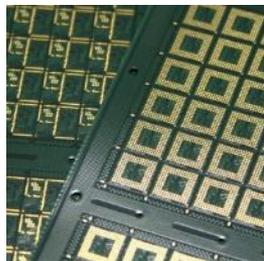
About Technic



- Technic is a privately held, global company with a belief in innovation and employee empowerment
- Approximately 1000 employees worldwide
- Strong financial resources and stability
- Various ISO 9000 approved facilities
- A strong commitment to new product research & development
- Annual Sales volume in excess of \$400,000,000



About Technic – *Company History*



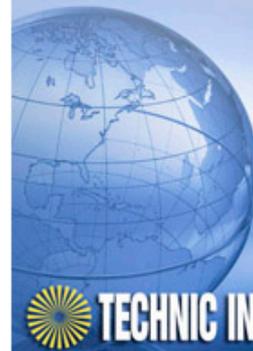
Technic is a Rhode Island, USA based private company

- Family owned since inception
- Incorporated in 1944
- Original focus of the business was precious metal supply to the decorative / jewelry industry in the Providence, RI area

Expansion into the electronics industry in the 1950s

Technic has grown to be a leading global supplier of;

- Specialty Chemicals
- Surface Finishing Equipment
- Engineered Powders
- Analytical Control Systems



About Technic - *Technic Business Units*

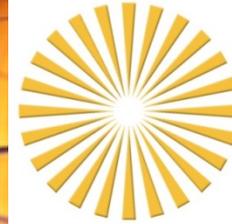


- Corporate Headquarters / Specialty Chemicals / Precious Metals, Cranston, RI, USA
- Equipment Group: Pawtucket, RI; Clearwater, FL; and Singapore
- Engineered Powders: Woonsocket, RI, USA
- Plating Services: Suzhou, China
- Semiconductor Applications Lab: Anaheim, CA USA
- Ultra-Pure Chemicals: Paris and Chalon, France
- Metal Concentrates (SCS): Royersford, PA, USA
- In addition, regional sales & service offices provide representation in all major markets



Advanced Engineered Solutions

A Global Leader in
Specialty Chemicals,
Surface Finishing Equipment,
Engineered Powders,
and Analytical Control Systems



TECHNIC INC

Beyond Ni/Au: Next Generation Finishes for Electronics Applications



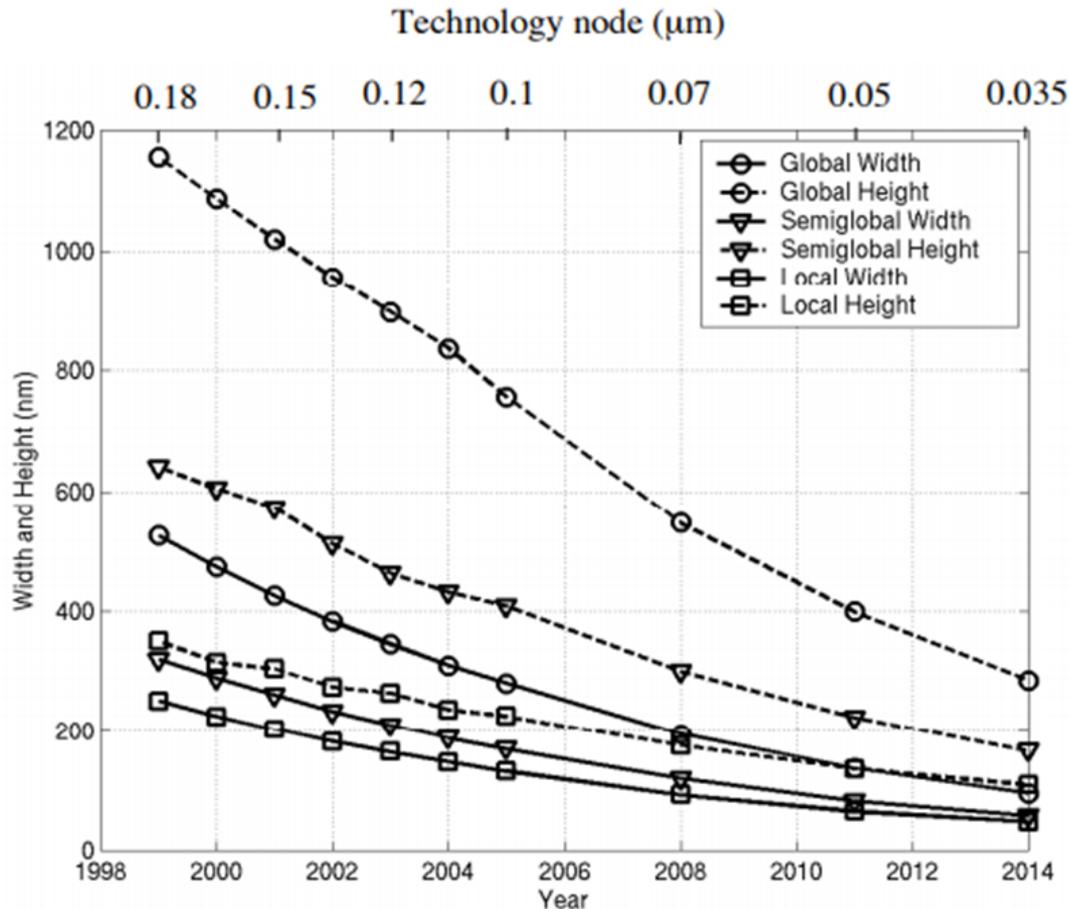
Beyond Ni/Au:

Functions of Electronic Finishes

- Provide electrical conductivity
- Improve corrosion resistance
- Impart good wear resistance
- Enable attachment to other surfaces (where applicable)
 - Soldering, insertion, etc.
- Traditional electroplated Ni/Au deposits have achieved the above objectives successfully for decades
 - Ni: 1-2 μm +
 - Au: 0.1-0.75 μm (depending on application)
- **UNTIL NOW...**

Beyond Ni/Au: Electronic Finishes : New Requirements

As IC semiconductor devices and PCB dimensions are scaled down, the demands on the electronic interconnects increase dramatically

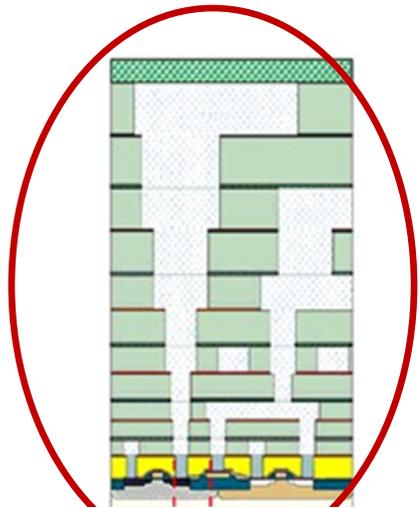


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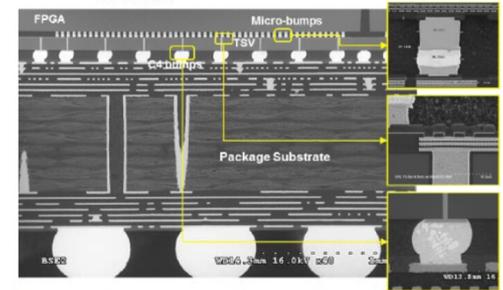


Beyond Ni/Au:

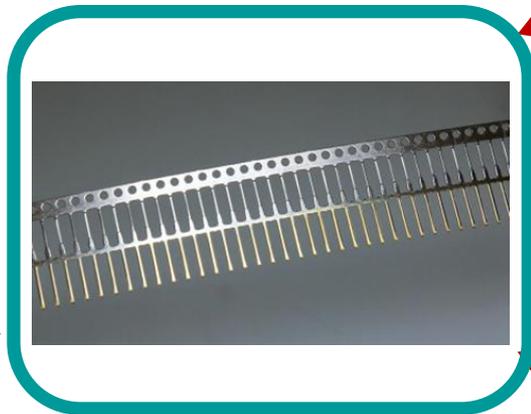
Electronic Finishes : New Requirements



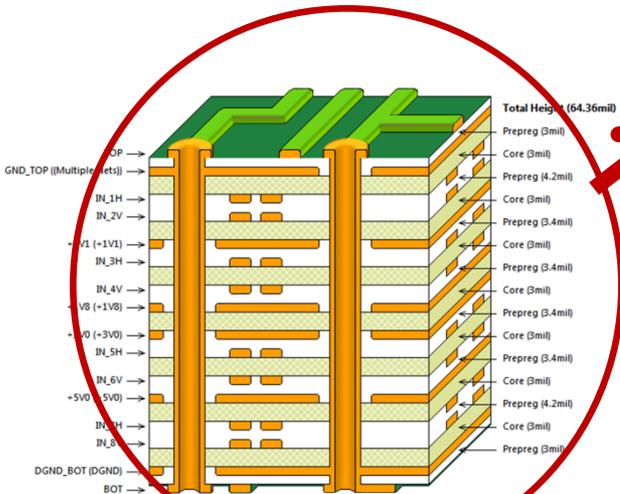
SEMICONDUCTOR



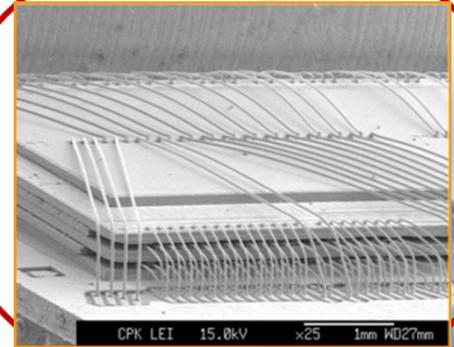
IC PACKAGING



CONNECTORS

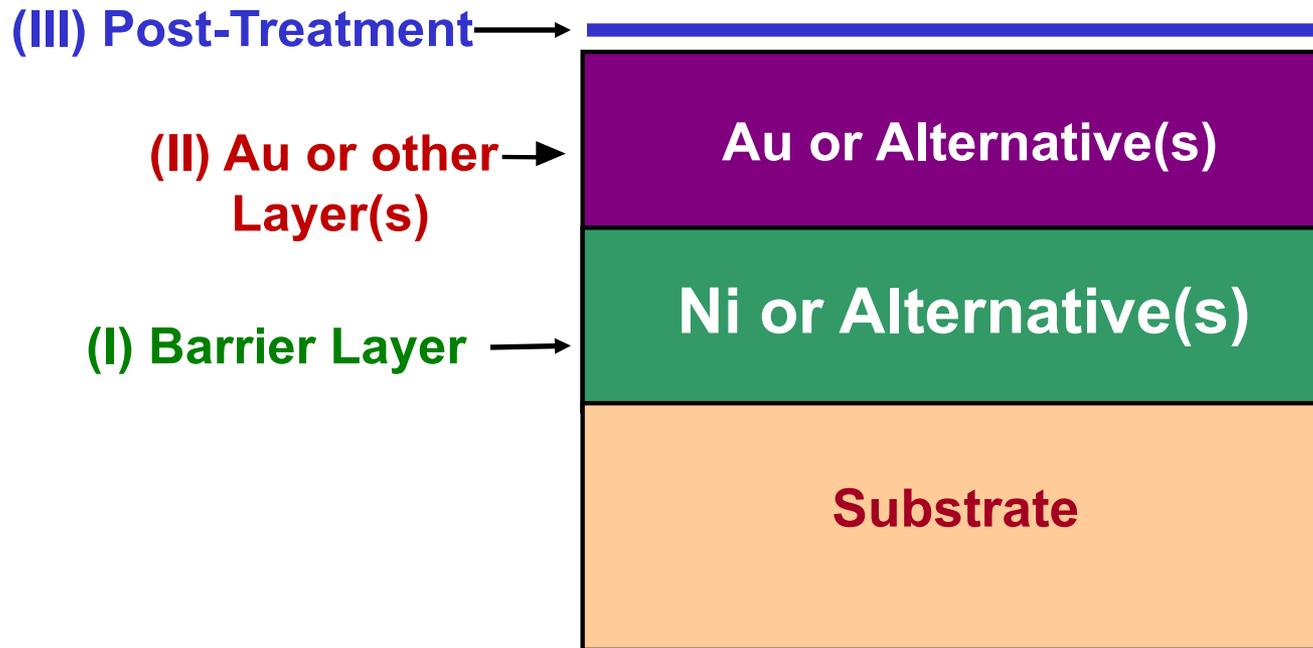


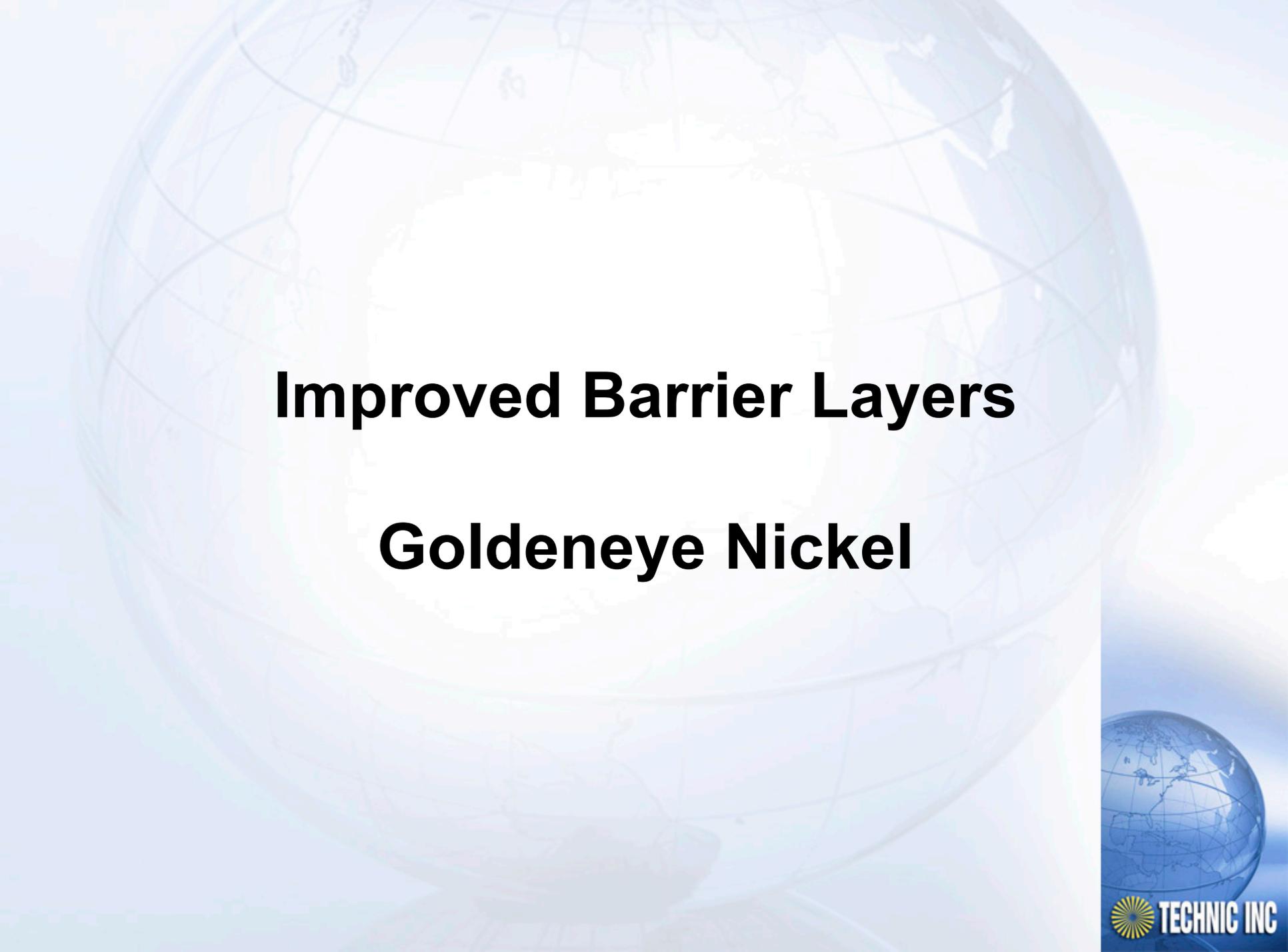
PCB



CONFIDENTIAL

Beyond Ni/Au: Typical Electronic Finish





Improved Barrier Layers

Goldeneye Nickel



Goldeneye Nickel

- Traditional barrier layer for electronics finishes is matte nickel sulfamate
- **Goldeneye Nickel** is an advanced nickel electroplating process specifically engineered to significantly improve nickel thickness distribution and corrosion-resistance from a proprietary electrolyte in high speed/reel-to-reel plating applications
- **Goldeneye Nickel** produces a semi-bright, low stress, ductile deposit



GE Nickel vs. Ni sulfamate

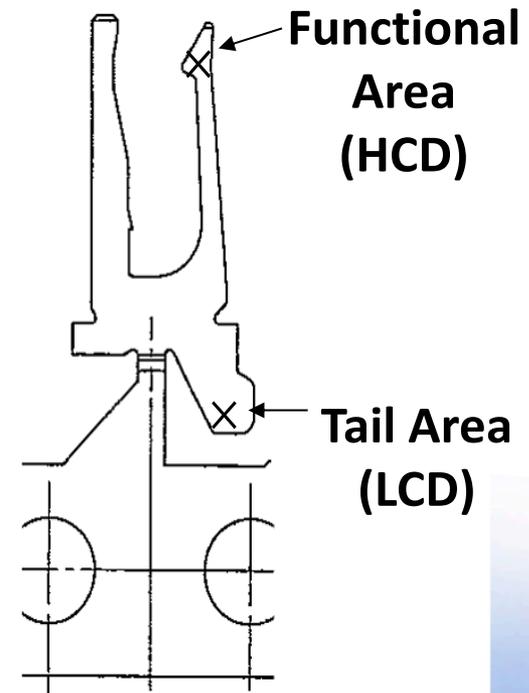
Deposit Characteristics		
	GE Ni	Ni Sulfamate Matte
Appearance	Semibright	Matte
Stress	~2500 psi (17.2 MPA)	~5500 psi (37.0 MPA)
Hardness	~450 knoop	~250 knoop
Structure	Nano-crystalline	Micro-crystalline
Solution Conductivity	155.6 mS/cm	68.0 mS/cm



Nano-crystalline Ni vs. Ni Sulfamate

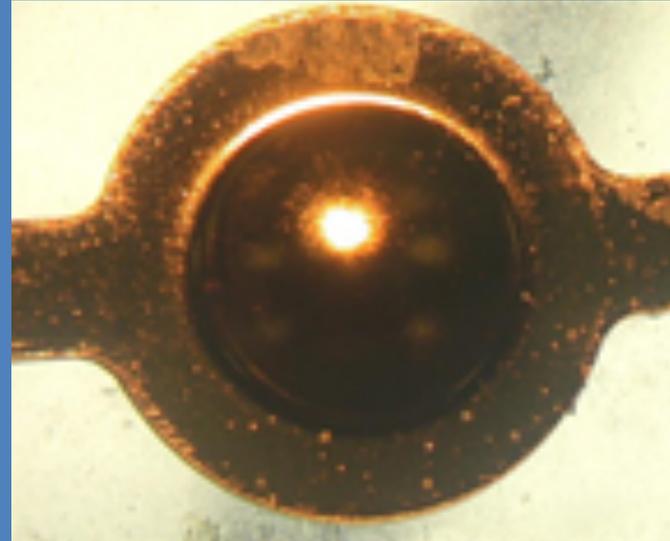
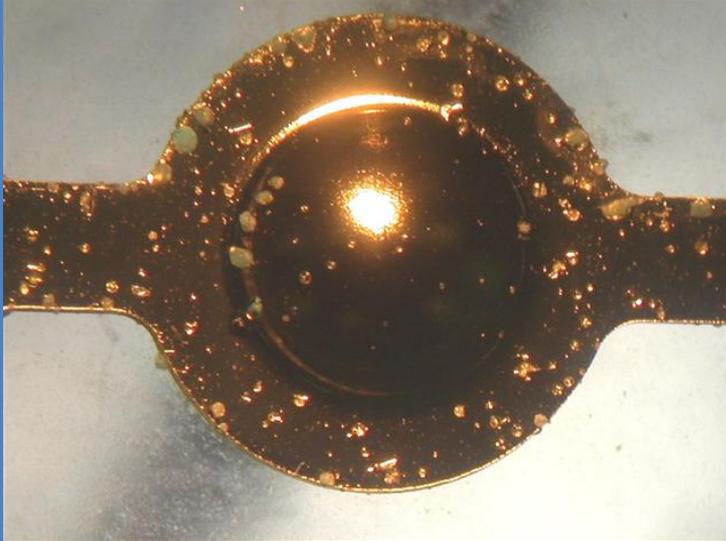
Thickness Distribution Comparison

Bath	HCD (μm)	LCD (μm)	HCD:LCD Ratio
Ni S.	1,04	0,36	2.9
GE Ni	1,09	0,56	2.0
Ni S.	2,13	0,81	2.6
GE Ni	2,18	1,24	1.8
Ni S.	3,12	1,19	2.6
GE Ni	3,07	1,83	1.7



The thickness distribution of the Low Current Density (LCD) area is significantly improved (30 to 40%) by Nano-Ni process.

Nano-Crystalline Nickel vs. Ni sulfamate Corrosion Comparison



Ni sulfamate - 3,05 μ m
Au - 0,76 μ m

Nano-Ni - 2,54 μ m
Au - 0,76 μ m

After 2 hour nitric acid vapor (NAV) exposure

Goldeneye Nickel Product Portfolio

- GE Ni has evolved from its original application as a Ni sulfamate replacement for gold-savings applications to become a more significant nanocrystalline barrier layer and/or final finish technology in multiple applications:
 - Goldeneye Nickel / GE Ni II / GE Ni III
 - Goldeneye Level Nickel HS
 - Goldeneye Satin Nickel
 - Goldeneye Black Nickel
 - Goldeneye Matte Nickel
 - Goldeneye Nickel-Iron
 - Goldeneye Nickel-Tungsten
 - Goldeneye Cobalt-Tungsten
 - Goldeneye Nickel EF

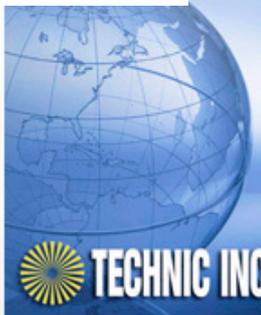


Goldeneye Technology – New Logo



Goldeneye

Advanced Nano-Plating Technology



Goldeneye Nickel Tungsten



Goldeneye NiW

- Alloy composition: 60/40 \pm 10% Ni/W
- Hardness: 640 HV
- Deposit structure: Nano-crystalline
- Stress: 10-20K psi
- Highly corrosion resistant
- Improved wear resistance compared to nickel
- DC plating; no special rectification required
- Wide operating window



Cobalt-Tungsten (CoW) A Nickel-Free Barrier Layer

- For certain applications, elimination of nickel entirely from the plated layer system is desirable (e.g., Ni dermatitis)
- **Cobalt-Tungsten alloy (CoW) barrier layer** electroplating technology has been developed for these applications

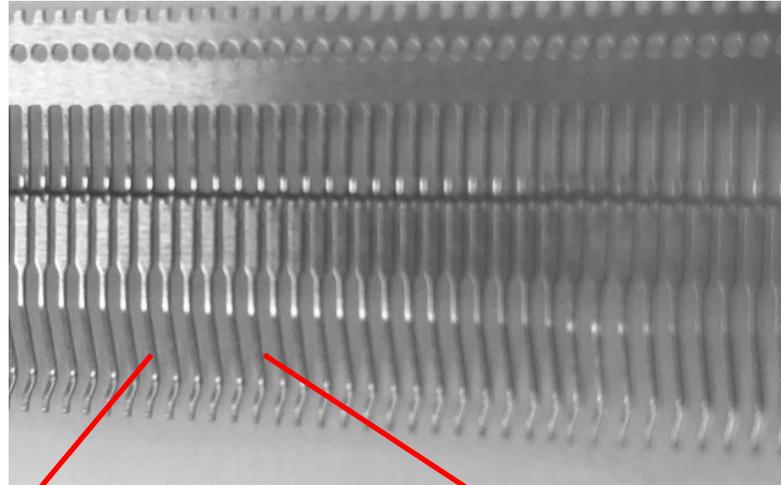


CoW Properties

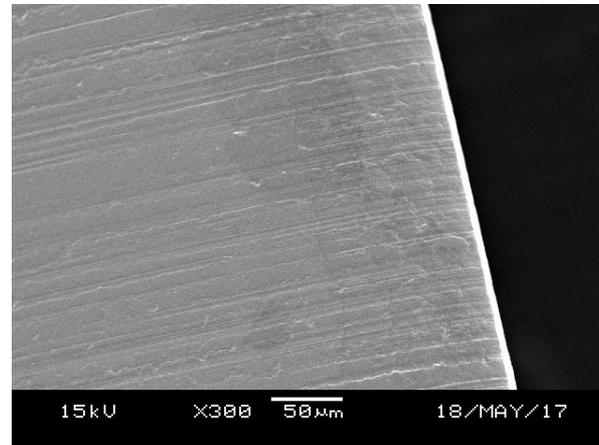
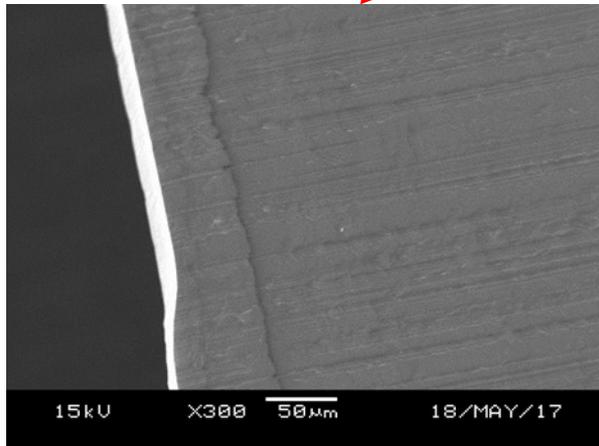
- Alloy composition: 65/35 \pm 5% Co/W.
- Hardness: 600-700 HV
- Deposit structure: Nano-crystalline
- Wide operating window.
- Drop-in replacement for nickel or nickel-tungsten plating solutions in existing lines.
- Nickel-free deposit with no nickel dermatitis issues - suitable for consumer applications
- Low deposit stress
- Excellent corrosion-resistance



Cobalt-Tungsten Alloy Deposit Appearance



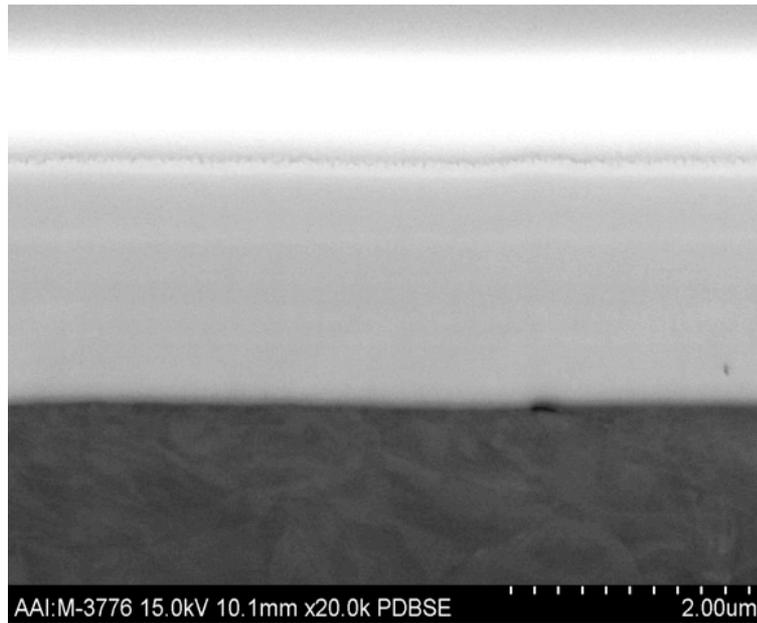
**15 ASD
65% Co-35% W**



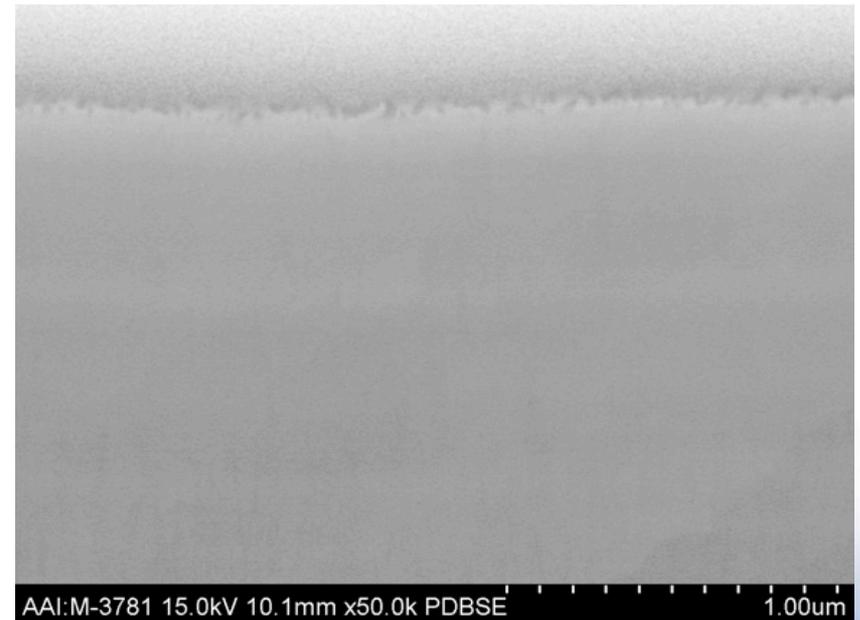
Cobalt-Tungsten Alloy

FIB / SEM Cross-section data

20,000X



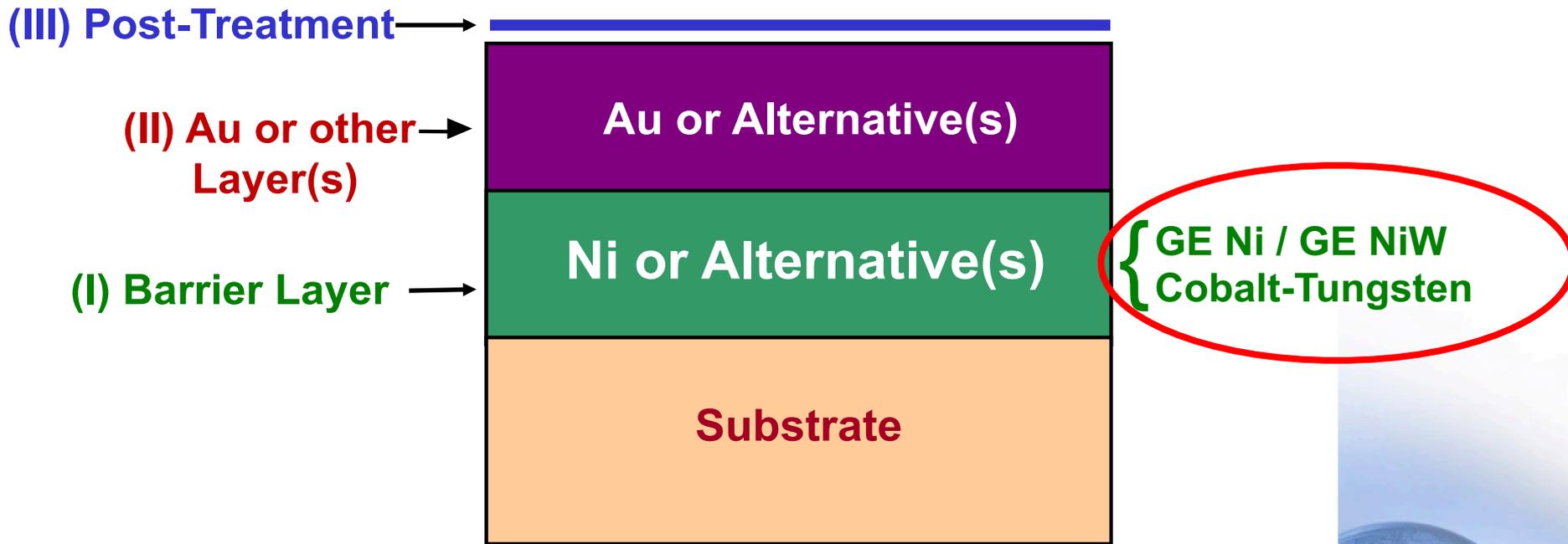
50,000X



CoW has nano-crystalline structure



Beyond Ni/Au: Typical Electronic Finish



Alternatives to Gold / Post-Treatment Processes

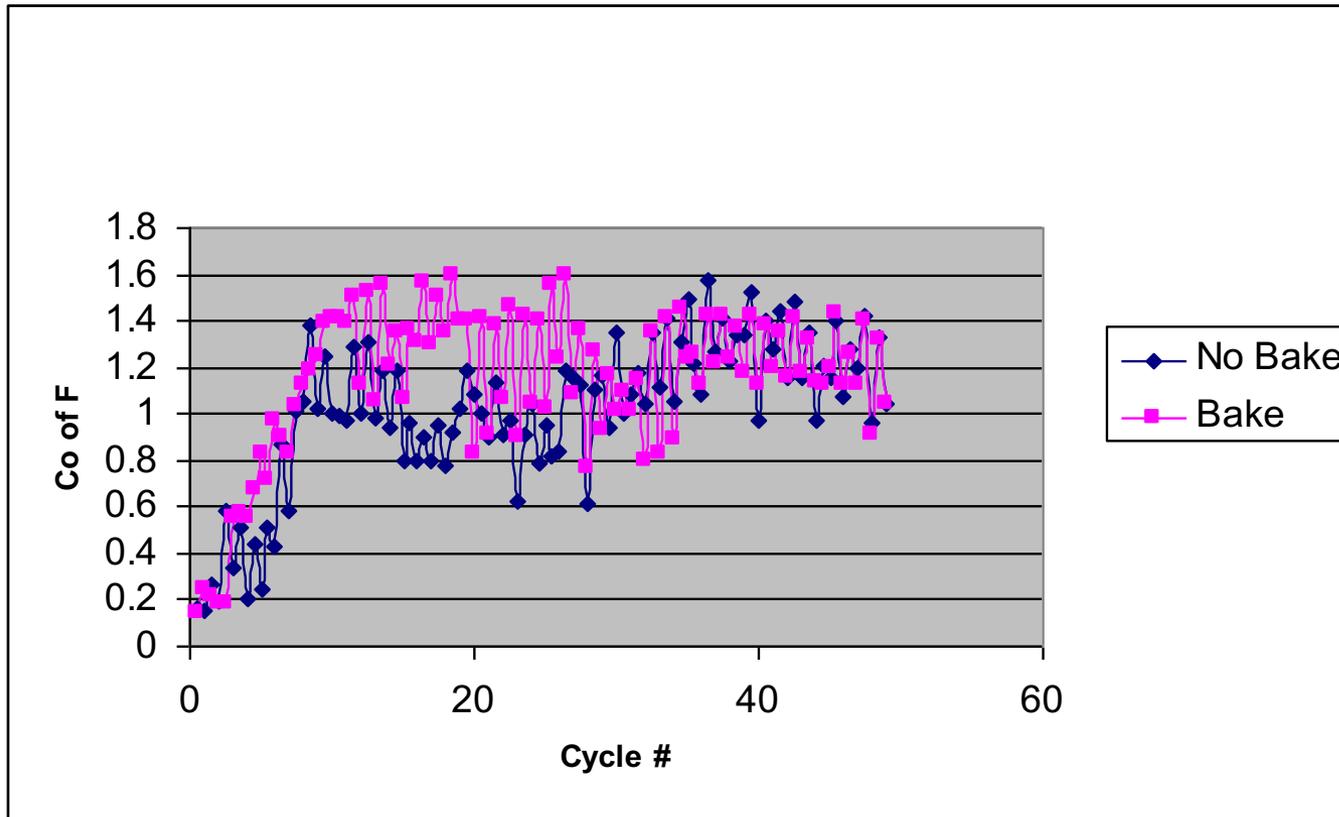


Silver on Connectors-Introduction

- Until today, 2 technical issues have limited silver's implementation in non-automotive applications
 - Wear resistance esp. after multiple insertion cycles
 - Corrosion resistance – overcoming the silver tarnish issue
 - Automotive use of silver is currently restricted to sealed applications with minimal insertions
- Solution: Wear-resistant /corrosion-resistant silver plating process



Conventional Silver Wear Resistance Results



CoF of conventional silver is high ~1.2 before & after bake

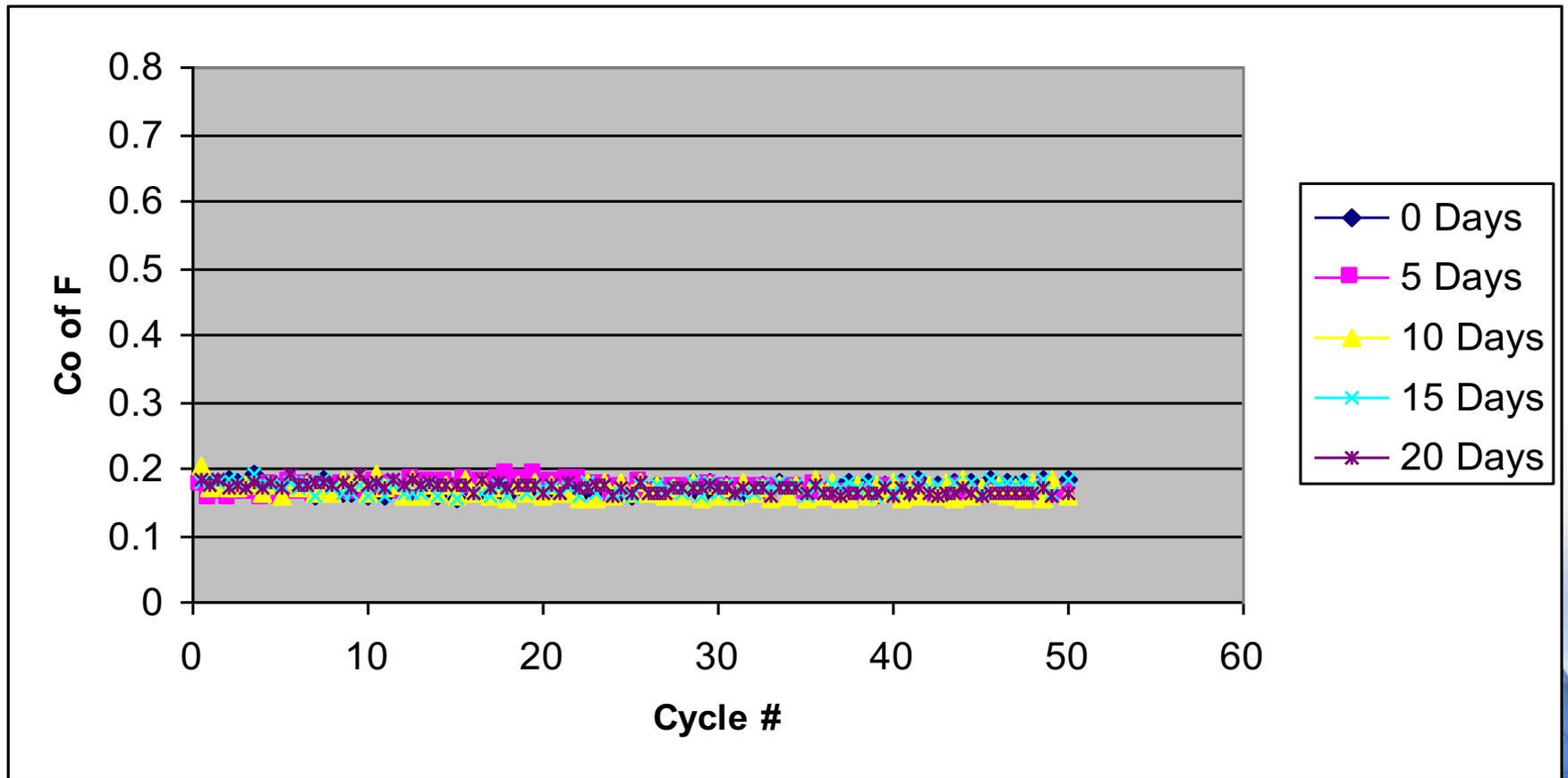


Silver Alloy Plating

- Silver alloy plating from a two-part system consisting of a silver alloy electroplated deposit and a unique post-treatment process chemistry.
- This combination provides excellent deposit conductivity combined with superior corrosion properties and significantly improved wear resistance compared to conventional silver.



***Durasil™* Wear Resistance Results** **With bake / 0-20 days MFG Exposure**

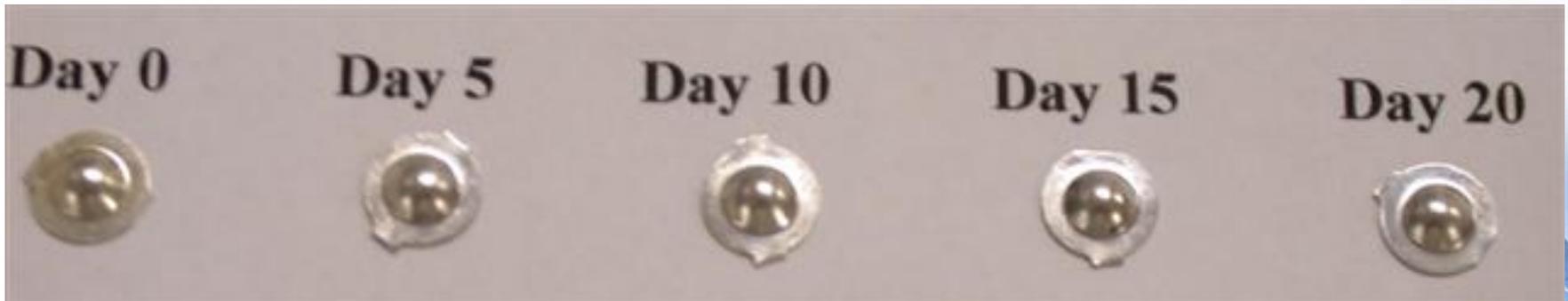


***Durasil™* Corrosion Resistance Results**

0-20 days MFG Exposure



Above: no bake
Below: with bake



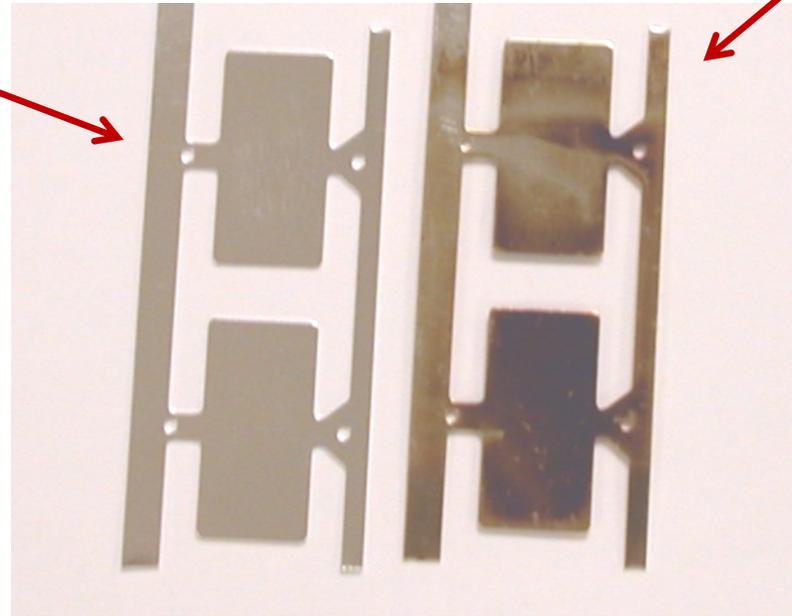
**Conclusion: Minimal to no corrosion observed
after 20 days MFG exposure**

Techniseal nano-coating on Silver Sulfur Corrosion Testing

5% K₂S Solution
Parts fully immersed for 5 minutes

With Techniseal

No Treatment



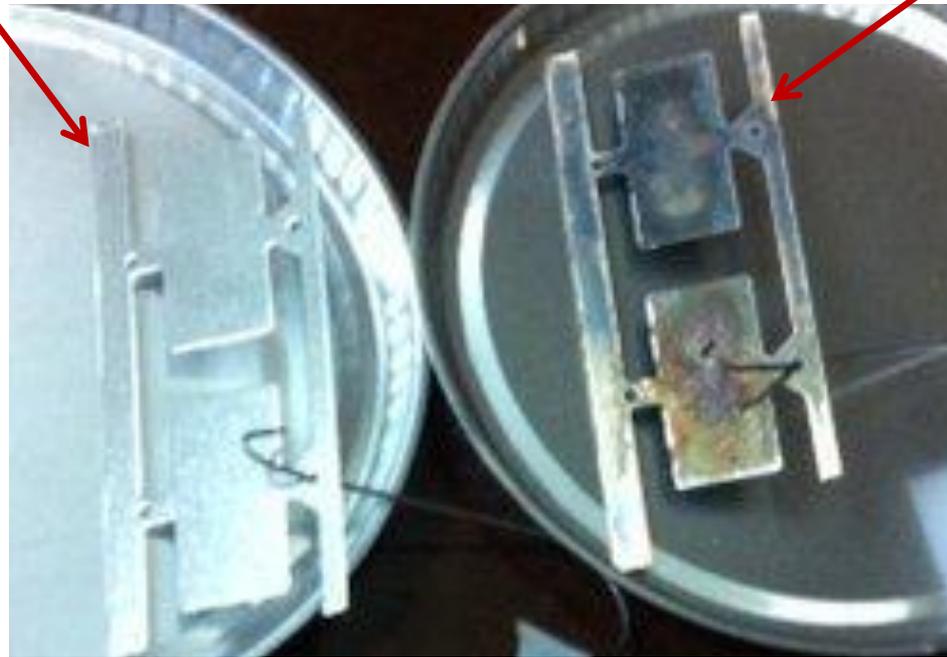
Techniseal nano-coating on Silver

Sulfur Corrosion Testing

Mixed Flowing Gas Exposure
per EIA-364-65B, Class IIa
5 days exposure

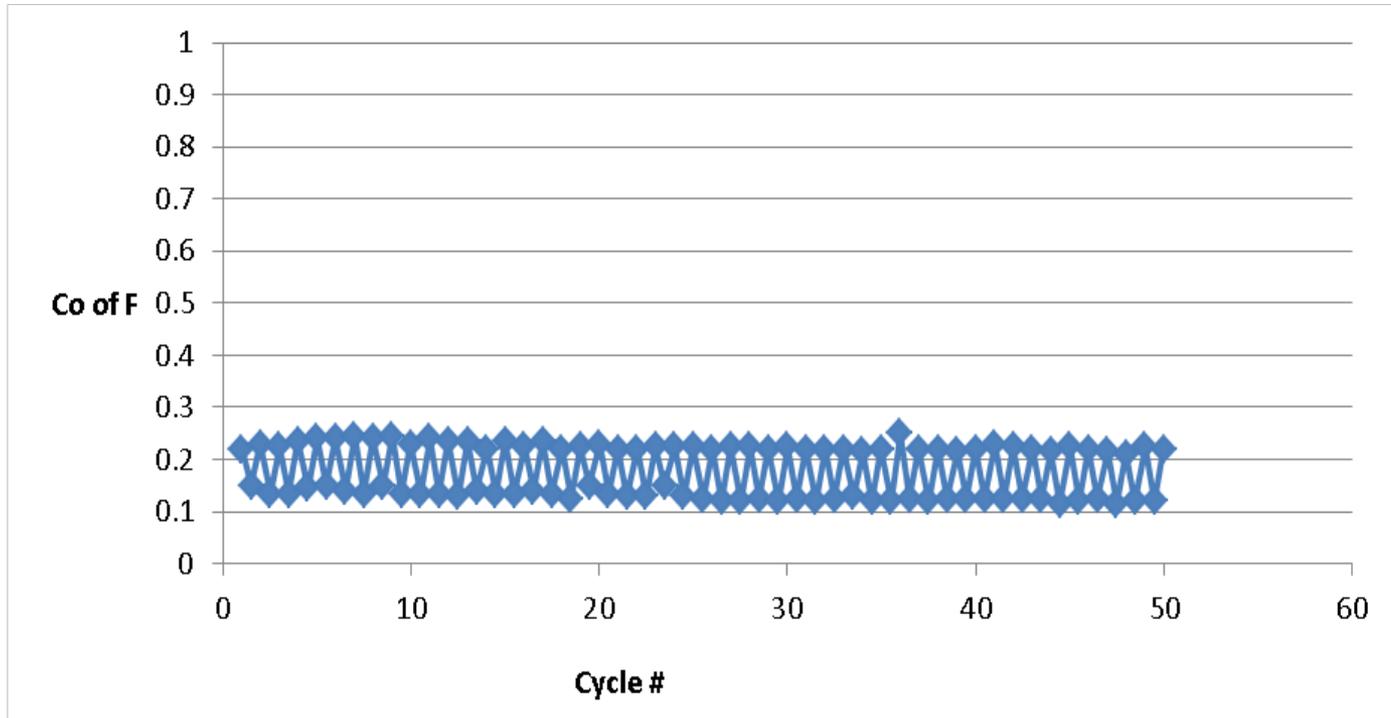
With nano-coating

No Post-Treatment



Nano-coating + lube

Wear Resistance Results



Excellent WR results equivalent to hard gold



Silver Alloy Plating

Summary

- Deposit Hardness ✓
 - 175 Knoop as-plated; 145 Knoop after bake
- Contact Resistance ✓
 - Low and stable CR (~2.5m-ohm), after bake and/or after 20 days exposure to MFG
- Wear Resistance ✓
 - Low and stable CoF (~0.2) , after bake and/or after 20 days exposure to MFG
- Corrosion Resistance ✓
 - Minimal to no corrosion after 20 days exposure to MFG
- Solderability ✓
 - Passes J-STD-002C after 500 hrs bake

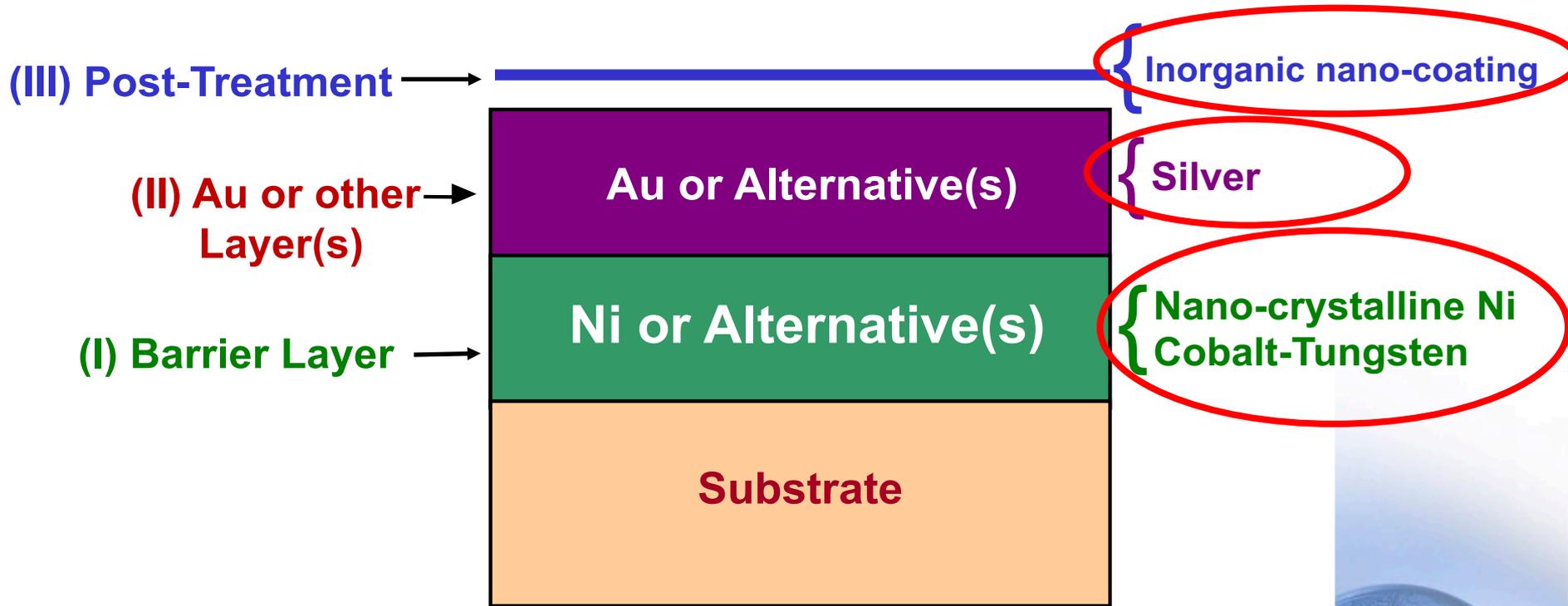


Silver on Connectors Summary

- Several options exist :
 - Silver alloy plating + post-treatment
 - Silver plating with nano-coating for corrosion protection only
 - Silver plating with 2-step post-treatment process sequence consisting of nano-coating + Post-Dip (lube), improvements in both silver protection AND wear resistance can be achieved
- These combinations provide similar technical performance comparable to hard gold in connector and related applications



Beyond Ni/Au: Typical Electronic Finish



Emerging Applications Requiring Completely New Electronic Finishes:

- **Electrolytic Sweat Resistant (ESR) Connector Finishes**
 - **Press-Fit Connector Pins**
- **High Frequency Applications (5G)**



Mobile Phone Connector Plating Technology Shift

- Two recent changes in cell phone technology are having a major impact on the plated finishes used for mobile phone connectors:
 - I. **Replacement of traditional headphone jack with a single connector that performs both the electrical charging function and the headphone connection**



Mobile Phone Connector Plating Technology Shift

II. Implementation of 'quick-charge' connector technology



Conventional Charging

5V / 1 Amp



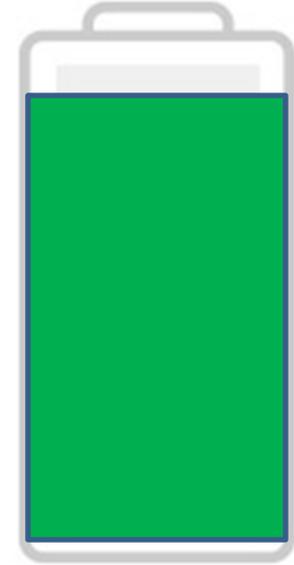
Quick Charge 1.0

5V / 2 Amps



Quick Charge 2.0

9V / 1.7 Amps
18W max.



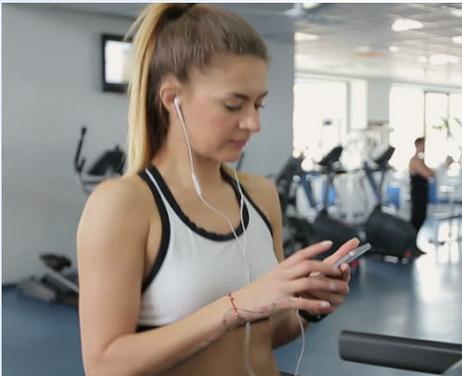
Quick Charge 3.0
3.2-20V / Dynamic
18 W max.

Increasing volts/amps through connector

How does this affect Mobile Phone Connector Plating Technology?

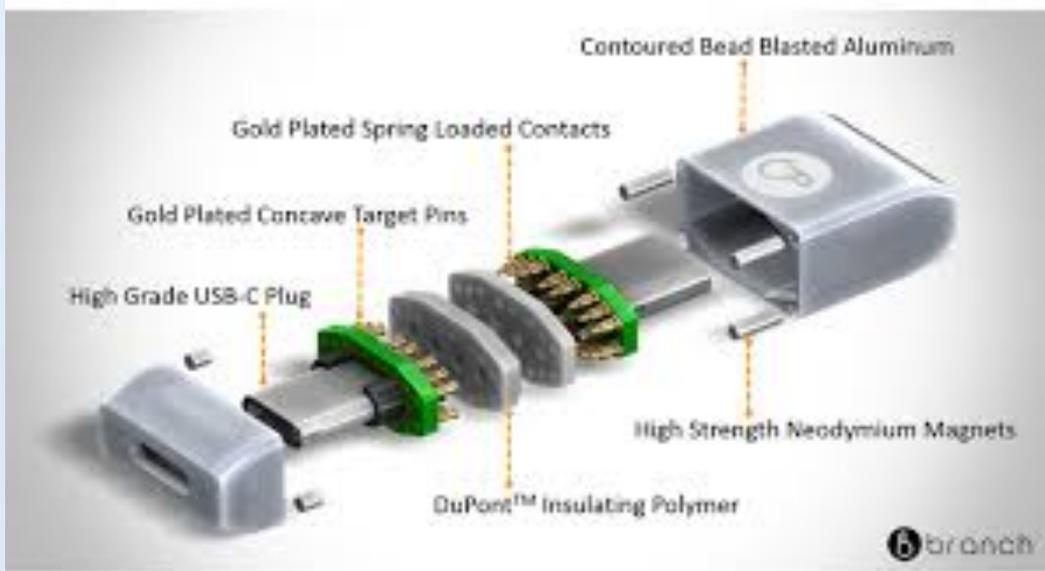
- I. Consumers exercising while using head phones &/or charging their cell phones (i.e., handling the connector) results in human sweat being present on the plated connector in the presence of electrical current

Sweat + Electrolysis = CORROSION



II. This electrolytic sweat-induced corrosion issue is made more severe when combined with the higher charging current/volts of quick charge technology

USB-C Connector Pins

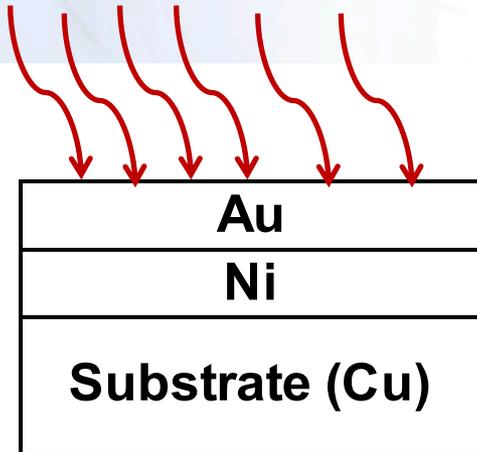


Mechanism of Corrosion Using Various Test Methods

NAV Test



Nitric Acid Fumes

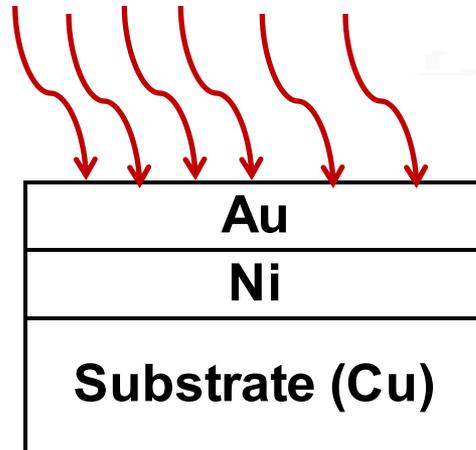


Mechanism =
Corrosion occurs
from outside to inside

NSS Test



NaCl Mist

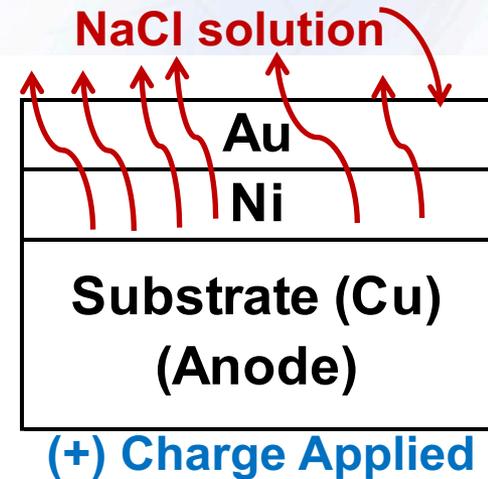


Mechanism =
Corrosion occurs
from outside to inside

Electrolytic Sweat Test



Cathode (-) Charge Applied



Mechanism =
Corrosion occurs
from INSIDE to OUTSIDE



Requirements for Passing ESR Testing

- Base material preparation is critical
- Extremely corrosion-resistant barrier layer(s) is (are) required
 - Ni cannot be used for high-end applications
- Top layer must be a Rh-containing deposit (resistant to electrolytic sweat solution)
 - No gold (gold is easily attacked/corroded during ESR testing)
- Optimal layer system to be selected depends on trade-off of performance vs. cost

Electrolytic Sweat-Resistant Finishes

- *Every major cell phone company in the world is now investigating the implementation of multi-layer stacks with Rh-based final finishes for their sweat-resistant / quick-charge connector applications*



Optimal layer system to be selected depends on trade-off of performance vs. cost

ESR Performance vs. Cost Summary

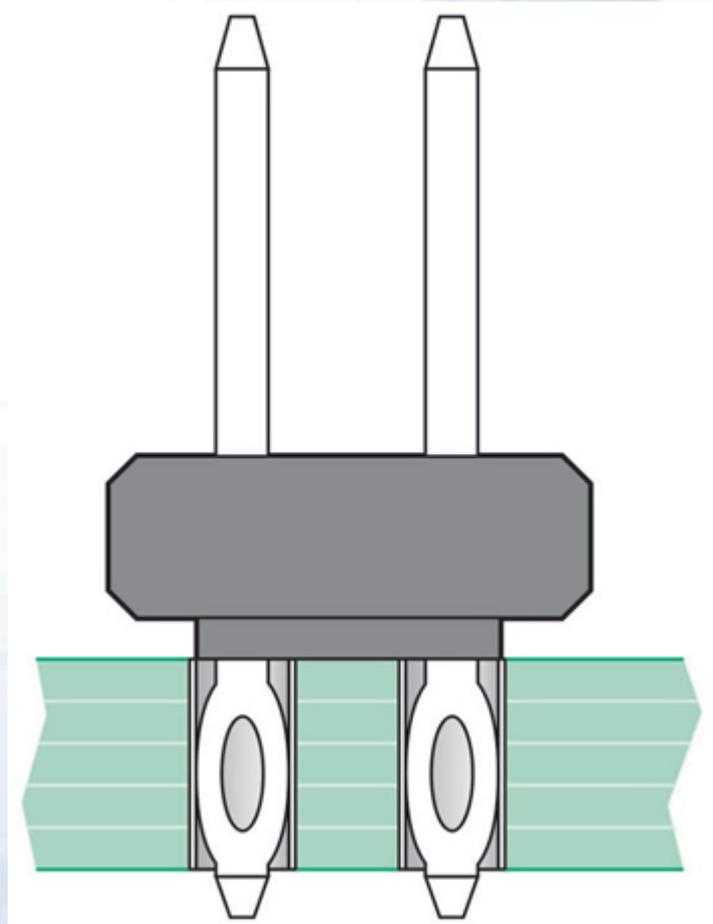
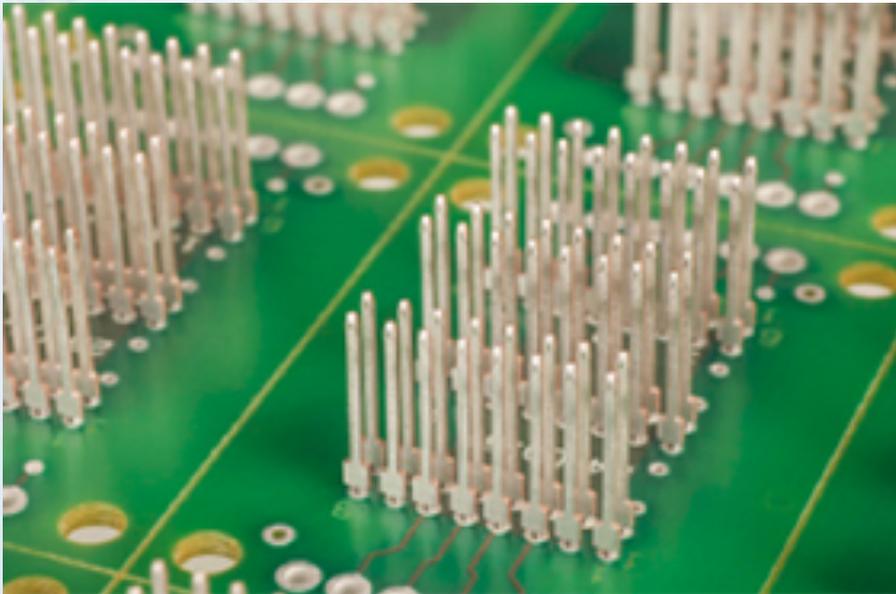
Classification	ESR	
	Performance	Cost
Low-End	3-4 minutes	1.5 X
Mid-End	4-20 minutes	2.4 - 7X
High End	20-40 minutes	7 - 10 X
Ultra High End	40-70 minutes	10 - 12X

Top Global Cell Phone Companies – Sept. 2018

Manufacturer	Smartphone shipments year-to-June 2018	Year-on-year change	Market share in Q2
Samsung	307.5 million	-1.9%	21.0%
Huawei	174.7 million	+14.9%	15.9%
Apple	217.5 million	+0.9%	12.1%
Xiaomi	116.7 million	+81.9%	9.5%
Oppo	111.9 million	+0.6%	8.6%
Vivo	93.4 million	+8.6%	7.9%
Lenovo	47.0 million	-9.1%	3.0%
Others	377.4 million	-23.1%	22.0%
Industry total	1.45 billion	-2.6%	100%

Source: IDC

New Plating Technology for Connector Press-Fit Pin Applications

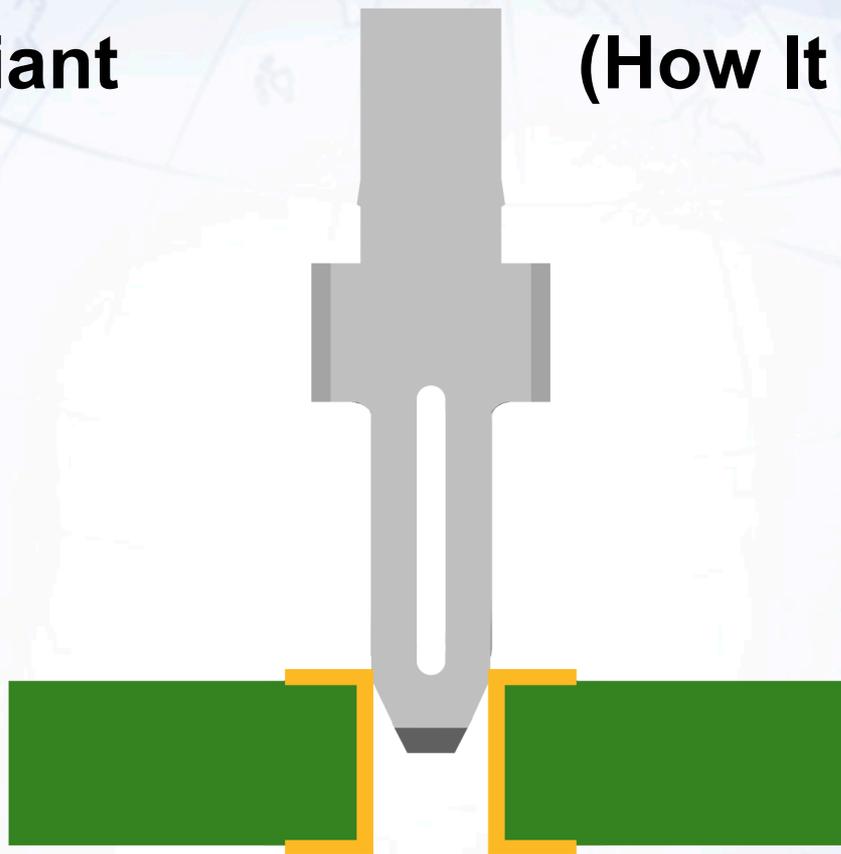


Press-fit technology is the insertion of flexible or rigid connector pins into plated through holes (PTHs) of printed circuit boards without soldering. The technology is industry accepted, widely used, reliable, and easy to operate.



Compliant

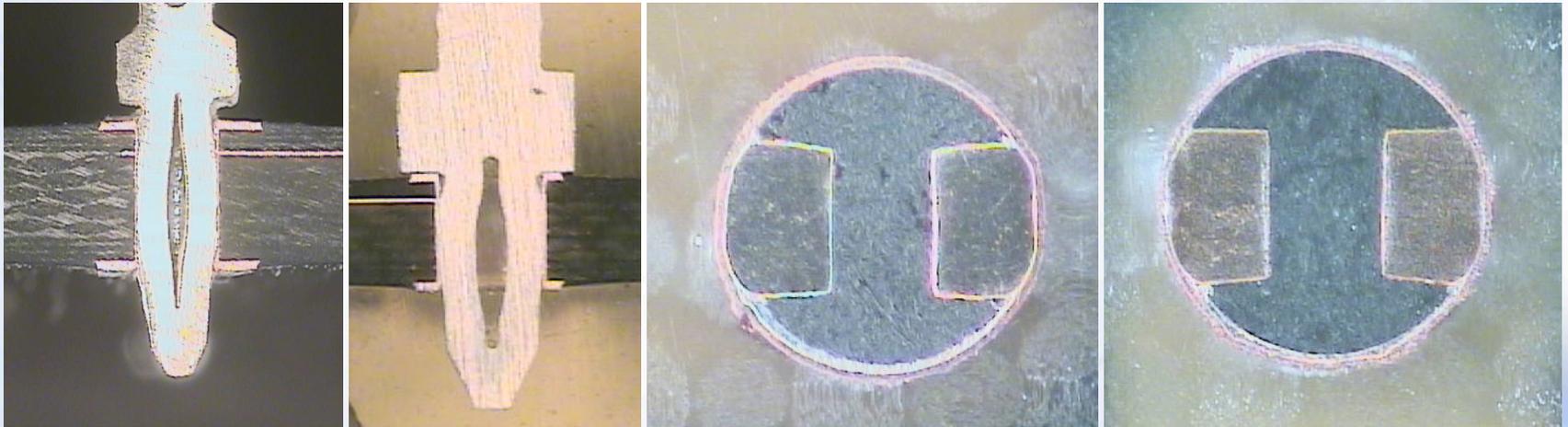
(How It Works)



MINIMAL PTH
DEFORMATION



Terminal Cross Sections in PCB



0.81mm THICK TERMINAL

Advantages of press-fit technology vs. soldering

1. Prevention of thermal stress on the PCB and no soldering
2. Eliminating pins damage or breakage, solder bump or flux residue, etc.
3. Avoidance of short, cold solder connection, corrosion, etc.
4. Enable Plugins to connect with plugs directly, and no need for screws
5. Connectors with long pins can be connected from the backside of the PCB, for no soldering
6. Reparability that the connector or a single pin can be replaced easily
7. Stable and low contact resistance, good high frequency characteristics
8. No need to wash PCBs and prevention of polluted substances like fluxes for no soldering
9. High efficiency and low cost
10. Green technology , no solder or flus to store or recycle



Connector Press-Fit Pin Plating Technology - Introduction

- Matte tin has resulted in extremely long whiskers under certain press-fit conditions
- Connector companies and/or end users have been experimenting with various non-tin solutions for years
- Recently three alternative finishes have emerged as potential solutions for press-fit pin whiskers formed under compression
 - Ag/Sn
 - Indium
 - Bismuth



Silver-Tin

Introduction

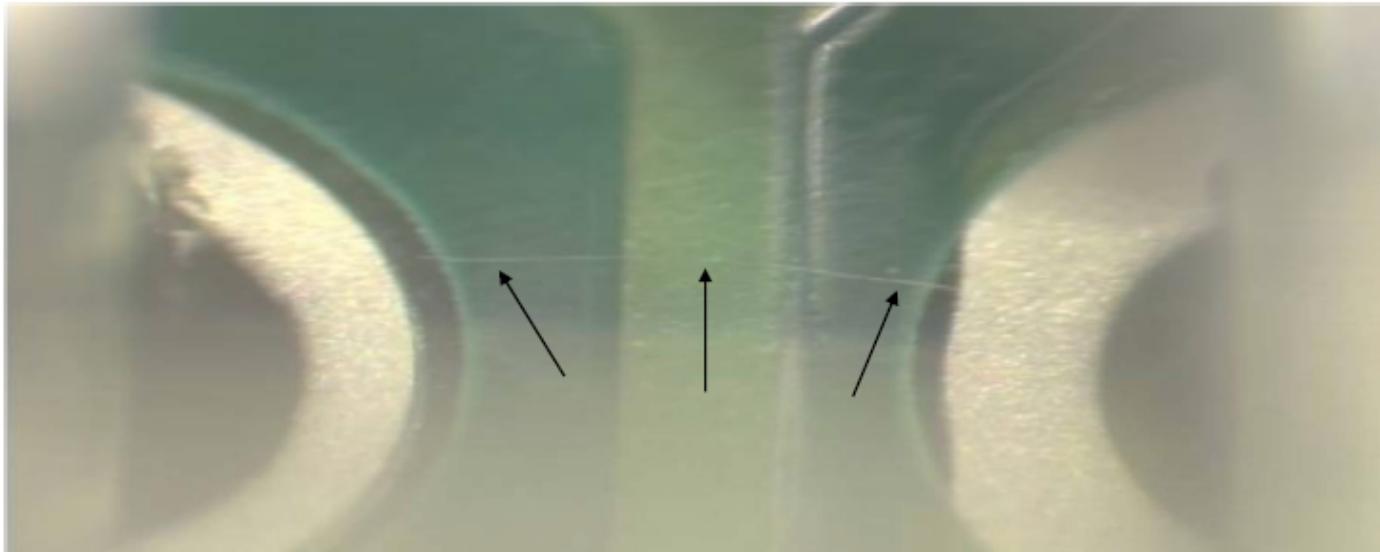
- Bosch has qualified Ag/Sn alloy (80% Ag; 20% Sn) as a press-fit connector finish
- Chemistry is difficult to work with; narrow operating window
 - Only one supplier has a commercial process (Dow)
- ATD is working on alternative approach of 2-layers Ag + Sn followed by 'reflow'
- New project; not much data available yet



Continental - Indium

Occurrence of short circuits

Whiskers potentially create short circuits or parasitary current paths. Fast growth of whiskers can be observed in press-fit connections due to high mechanical stress at pure tin surfaces.

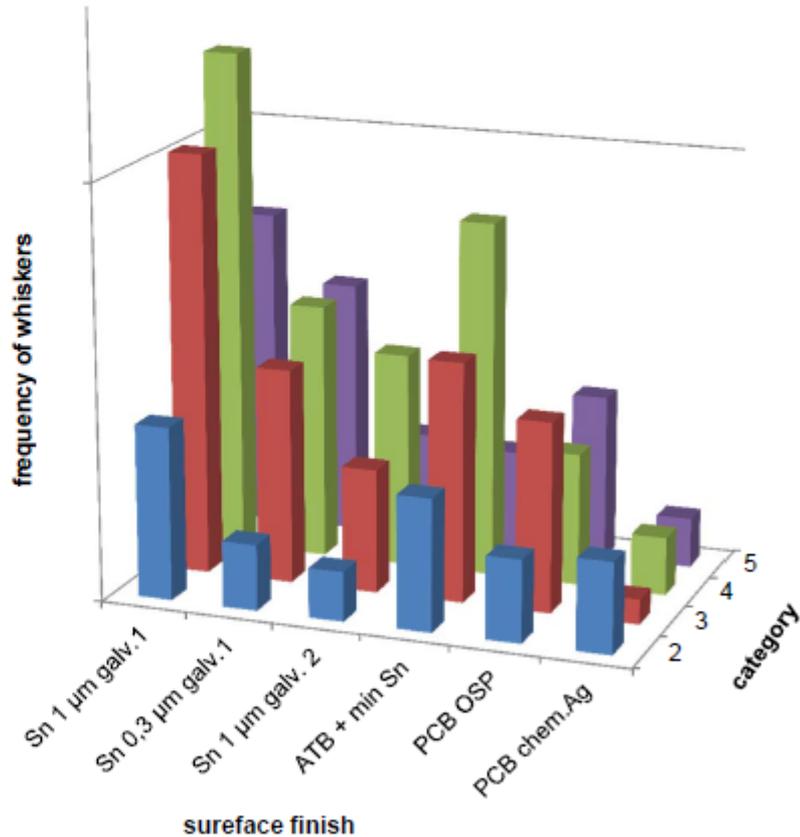


- ▶ Some 0-km and field returns identified at a body controller 2007
- ▶ Whiskers create direct parasitary signal path at sensor exits (very low current flow)
- ▶ Whisker length > 2 mm within 2-6 weeks after insertion in this case

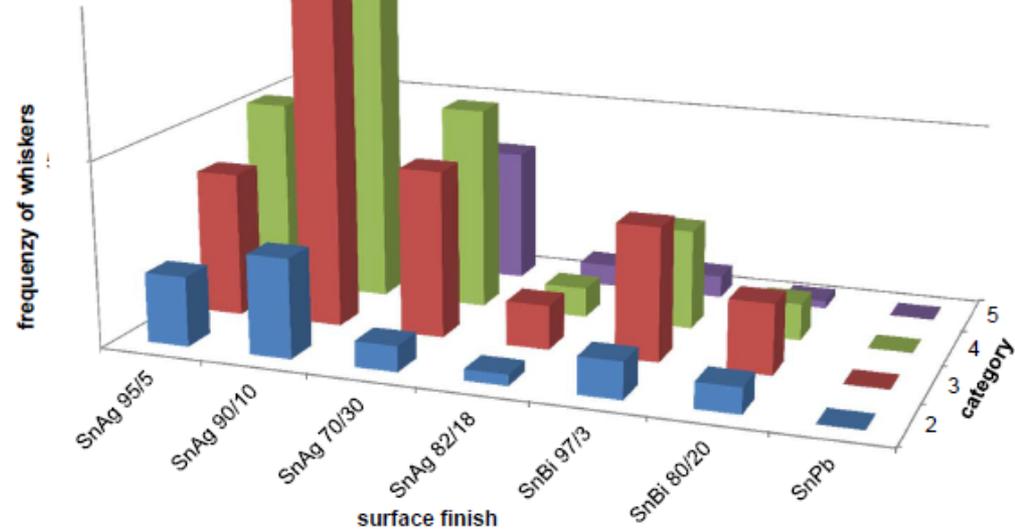
Direct bridging of low signal electrical contacts

Tin Whisker Growth Comparison

Pure Sn finish (over Ni)



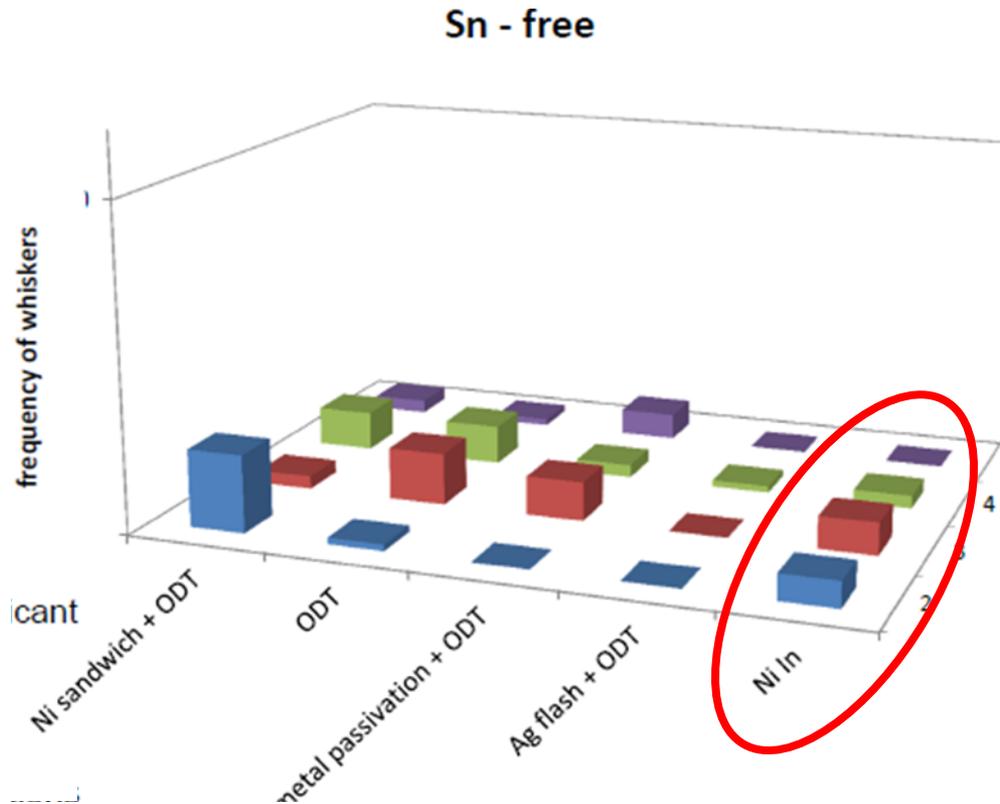
SnXy - finish (over Ni)



Source : “Whiskers and Alternative Surface Finishes at Press-in Technology”
 Dr. Hans-Peter Tranitz, Continental AG



Tin Whisker Growth Comparison



Indium is now a qualified/specified finish for Continental's press-fit applications

Source : "Whiskers and Alternative Surface Finishes at Press-in Technology"
Dr. Hans-Peter Tranitz, Continental AG



Continental – Indium Spec.

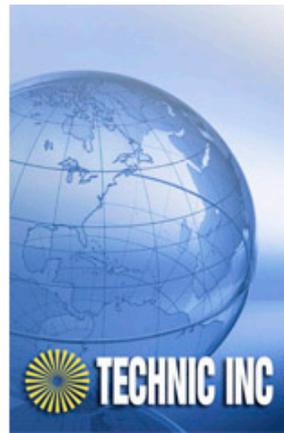
These requirements apply to new components with press-fit pins which will be introduced after this specification release date. Excluded are new components with press-fit pins arising from family concepts (e.g. variant of an existing product as pin coding, assignment).

Meeting these requirements for previously qualified components is preferred but not required.

Continental plating surface portfolio includes **Indium**, **SnPb (7+-3% Pb)** with known legal restrictions and **matte Sn**.

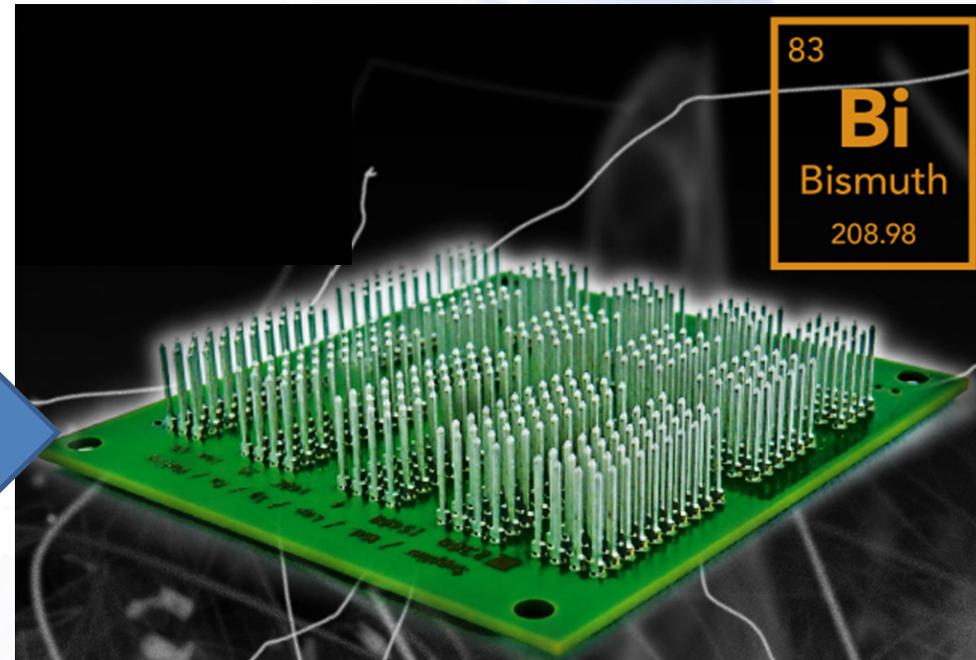
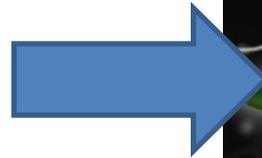
	Ni (barrier layer) /μm	Plating surface /μm
 Indium	2 ±1	0,7 ±0,4
SnPb (7+-3% Pb)		
Matte Sn		

Plating requirements are "whisker reduced", for detailed requirements see chapter 6.4 "Whisker analysis".



Press-Fit Pins Bismuth Plating

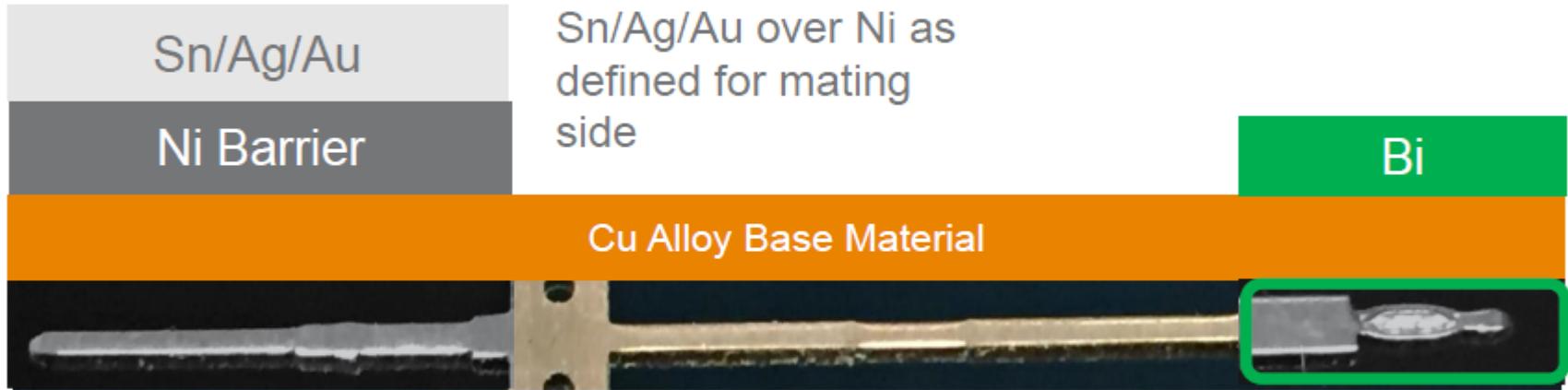
		Al	Si	P	S	
30 Zn	31 Ga	32 Ge	33 As	34 Se		
48 Cd	49 In	50 Sn	51 Sb	52 Te		
80 Hg	81 Tl	82 Pb	83 Bi	84 Po		
112	113	114	115	116		



Bismuth is also being considered as an option for certain press-fit applications

Source : "Litesurf –Tin-Free Electroplating for Press-Fit Technology," Frank Schabert
TE Connectivity, Webinar presented March 2018

LITESURF – Bi Press-fit Plating Technology



Nickel
Reduced

No
Intermetallic

Lean Plating
Solution

Press-Fit Connector Finishes Summary

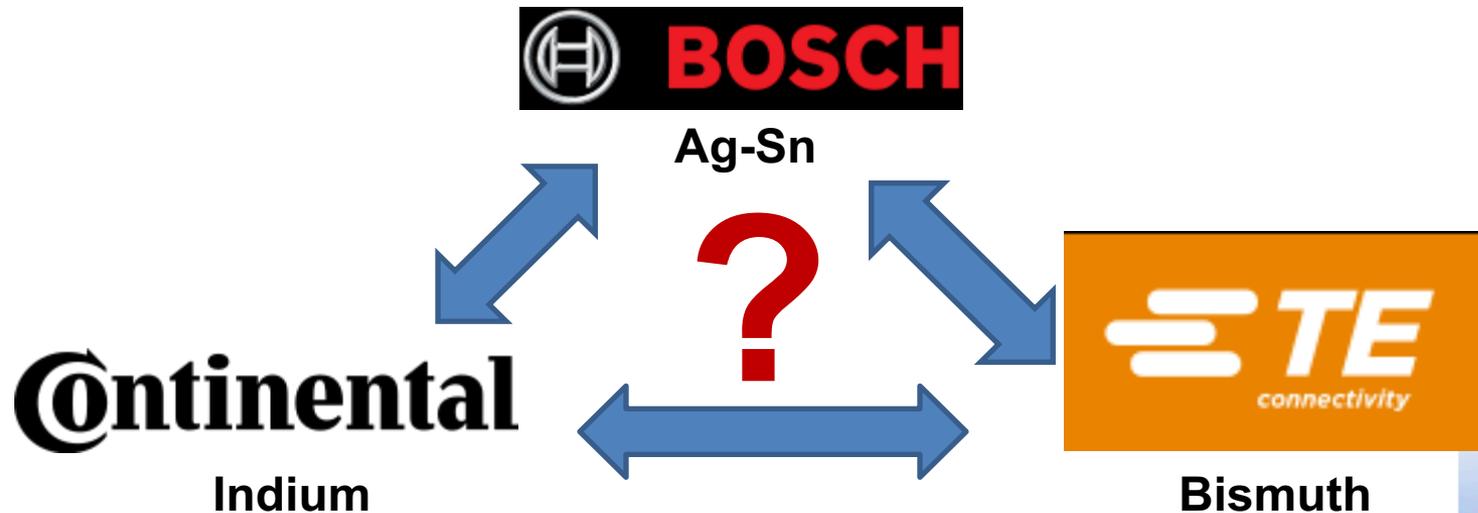
- Bosch has selected **Ag-Sn**
 - Several part types are specified with AgSn
- Continental has selected **Indium** as its preferred plating finish for press-fit pins
 - Several parts types are specified with In
 - Many connector manufacturers/plating companies are preparing In plating baths and/or samples for automotive companies
- Both Ag-Sn and In plating are “open” technologies; anyone can plate parts with AgSn for Bosch or In for Continental

Press-Fit Connector Finishes Summary

- TE has selected **Bismuth** as its preferred plating finish for press-fit pins
 - No known automotive suppliers have accepted Bi yet
 - “Proprietary plating process” developed by TE internally
 - Intended to be used solely on TE parts for several years
 - TE intends to license a chemistry supplier to blend and supply TE’s Bi plating formulation to others at some future date
 - No known patents on the application of Bi, or plated articles with Bi, have been identified yet
 - Can others supply Bi plated parts using alternative Bi plating chemistry? Nobody knows and TE is not talking!!

Press-Fit Connector Finishes Conclusions

- Which finish will win out?????

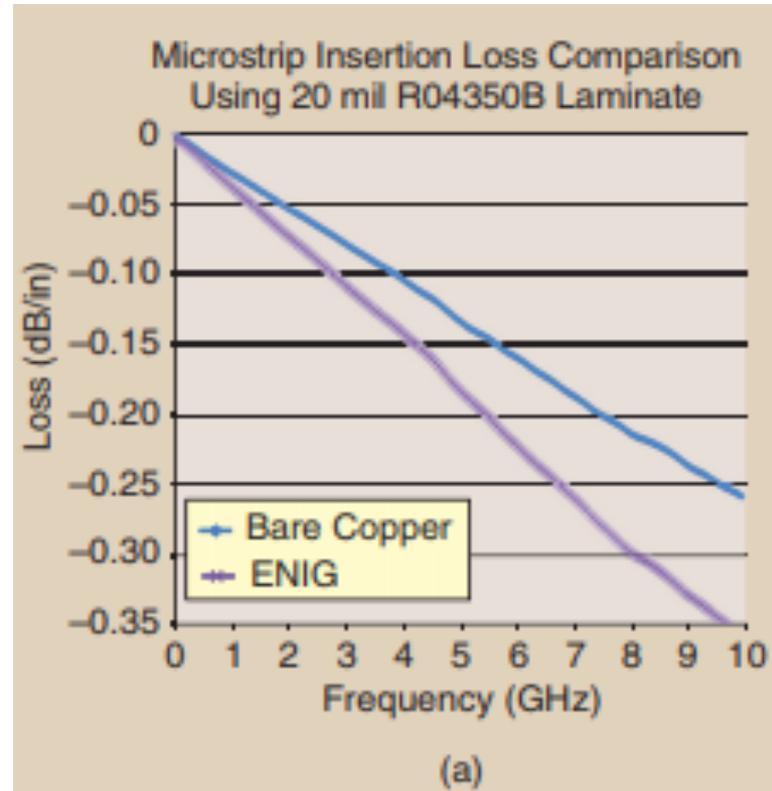
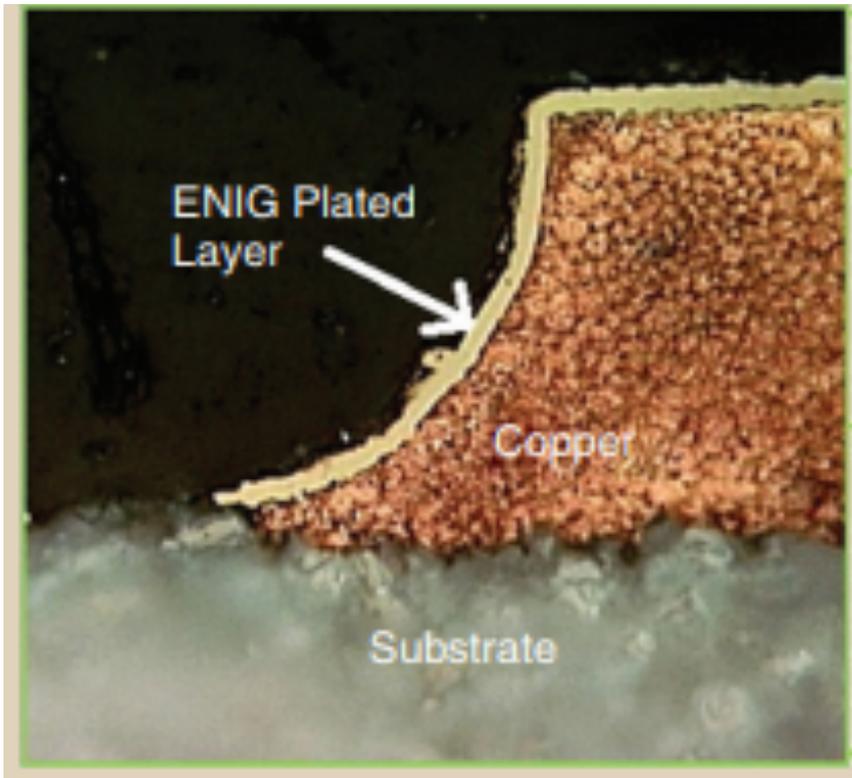


High Frequency Applications (5G)



Beyond Ni/Au: High Frequency Applications

Signal Loss vs. PCB Final Finish



Nickel deposit is the source of signal loss in high frequency applications

Source: "Ambiguous Influences Affecting Insertion Loss of Microwave Printed Circuit Boards"
John Conrod, IEEE Microwave Magazine, Issue 1527-3342/12

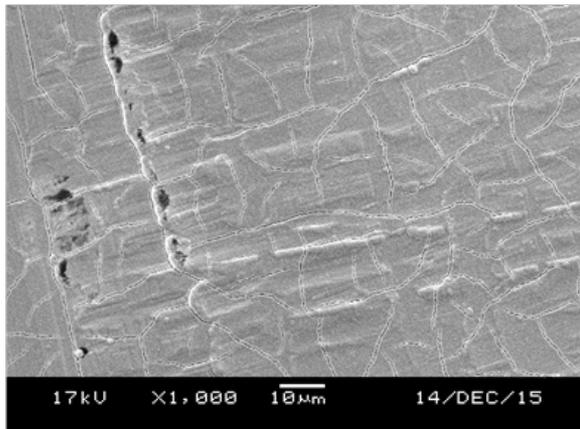
Connector Finishes for High Frequency Applications (5G)

- Ni-free barrier layer is required
- Good conductivity and corrosion resistance for final finish
- Palladium (Pd) is a suitable deposit that can function as both a barrier layer and a final finish
 - Barrier layer effectiveness requires relatively high thickness ($>0.75-1.0 \mu\text{m}$)
 - HOWEVER electroplated Palladium is notorious for micro-cracking at high thickness
- Solution : micro-crack free Palladium

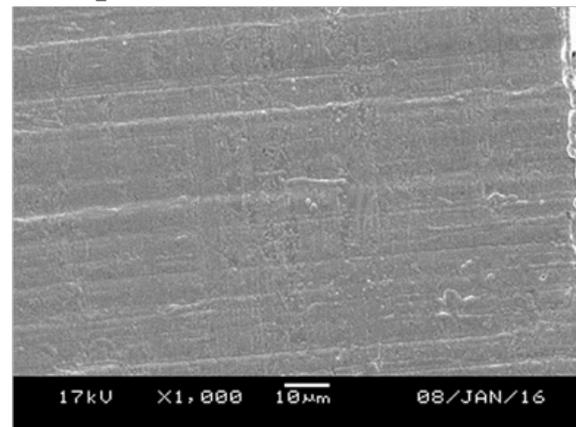
Low Stress/High Ductility Palladium

- Low stress deposits
 - No spontaneous microcracking up to 4 μm Pd thickness
 - No bending cracks (up to 2 μm)
- Neutral pH / no ammonia smell
- Wide current density range
- Stable electrolyte
 - >5 MTO bath life, with periodic c-treatment

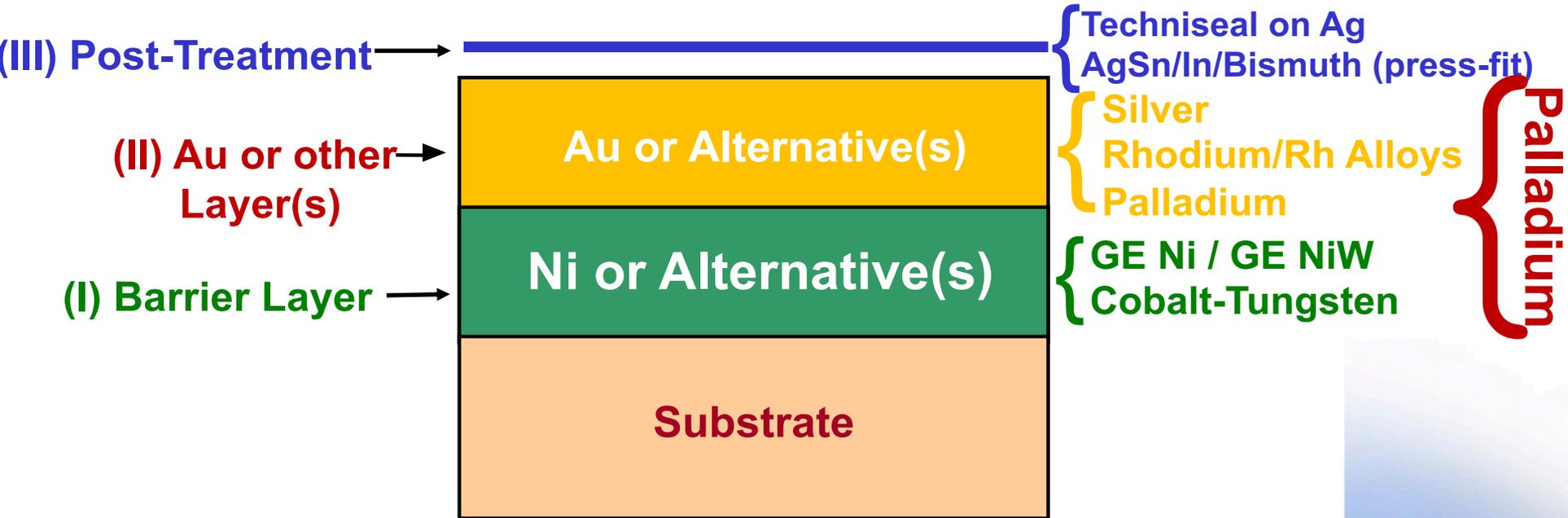
Conventional Pd-Cracked



High Ductility Pd- No cracks



Beyond Ni/Au: Summary



Beyond Ni/Au: Conclusions

- Rapid changes are occurring in an industry where conventional Ni/Au has been used for 4 decades
- Alternative finishes are being considered and/or implemented, including exotic materials never before considered feasible in a connector application
- We expect additional changes will occur as connector finish technology needs to keep up with the demands of the other interconnects and/or use environments



Thank you!

